

## Supporting Information

### **Synergistic Enhancement of Charge Extraction and Heat Dissipation in Inverted Perovskite Solar Cells via n-Doped Top Interlayers**

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## Experimental Section

### Materials

All chemicals utilized in the synthesis and device fabrication were purchased from Sigma-Aldrich, Tokyo Chemical Industry, and Alfa Aesar, and used without additional purification unless otherwise specified. [4-(3,6-Dimethoxy-9H-carbazol-9-yl)ethyl]phosphonic acid (MeO-4PACz, TCI), formamidinium iodide (FAI, Greatcell Solar), lead iodide (PbI<sub>2</sub>, TCI), cesium iodide (CsI, ultra-dry, 99.999% (metal basis), Alfa Aesar), fullerene (C<sub>60</sub>, 99.99%, OSM), and silver (Ag, 1-4 mm shot, 99.9999%, iTASCO).

### Synthesis

[6,6]-Phenyl-C<sub>61</sub>-butyric acid 2-[2-(2-methoxyethoxy)ethoxy]ethyl ester (PC<sub>61</sub>B-TEG) was synthesized by following the previously reported procedures.<sup>1-2</sup>

<sup>1</sup>H NMR (500 MHz, CDCl<sub>3</sub>):  $\delta$  (ppm) 7.94-7.82 (m, 2H), 7.56-7.53 (m, 2H), 7.49-7.46 (m, 1H), 4.25-4.23 (m, 2H), 3.70-3.63 (m, 8H), 3.56-3.54 (m, 2H), 3.38 (s, 3H), 2.93-2.89 (m, 2H), 2.55 (t, 2H,  $J = 7.50$  Hz), 2.22-2.19 (m, 2H).

### Instruments and Characterization

The <sup>1</sup>H NMR spectra were acquired using a Bruker Avance III HD 500 spectrometer. SEM images were captured using SU8220 Cold FE-SEM and SU7000 FE-SEM. AFM images were obtained using Dimension ICON (Bruker Nano Surface). XRD patterns were obtained using an X-ray diffractometer (D/MAX2500C/PC, Rigaku) with a Cu-rotating anode X-ray. The  $J$ - $V$  characteristics of the PeSCs were measured using an Ivium-n-Stat source meter under AM 1.5 G (100 mW cm<sup>-2</sup>) conditions. The EQE spectra were obtained using a QE measurement system (HS Technologies) by employing monochromatic light from a Xe lamp under ambient conditions. TPV and TPC measurements were carried out with a McScience T4000 (organic semiconductor parameter test system) at  $V_{OC}$  under illumination. XPS spectra were obtained by an Escalab 250Xi instrument (Thermo Fisher Co.), utilizing an Al K $\alpha$  monochromatic X-ray

source. Casa XPS software was employed for data analysis. UPS spectra were acquired through a UPS system (AXIS nova, Kratos Analytical), equipped with a helium ultraviolet source of 21.22 eV. The absorbance spectra were measured with a UV-Vis spectrophotometer (Ultrospec 2100 pro, Biochrom). EPR spectra were acquired using an electron spin resonance spectrometer (JEOL, JES-X320).  $I$ - $V$  curves were measured by incrementally raising the DC voltage by 10 mV steps from  $-2V$  to  $+2V$ , measuring the corresponding currents. PLQY was obtained using a UV-NIR absolute PL quantum yield spectrometer (Hamamatsu, C13534) with a high-power Xe lamp. IR camera images were obtained using PI640 microscope optics.

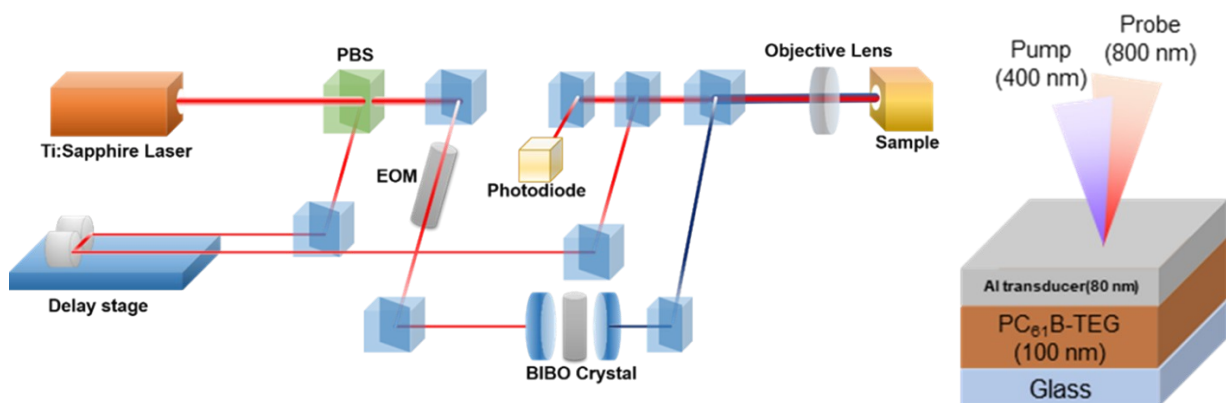
### Device Fabrication

$-0.000$  eV (TzTPT-INCN) and  $-0.000$  eV, respectively (TzCDT-INCN). The ITO-coated substrate ( $1.5 \times 1.5$  cm<sup>2</sup>) was subjected to a cleaning process using ultrasonication with acetone, isopropyl alcohol, and deionized water for 15 minutes each. Subsequently, a 30-minute UV ozone treatment was applied. The ITO was then spin-coated with a 3 mmol MeO-4PACz ethanol solution at 5000 rpm for 30 seconds and heated at 100 °C for 10 minutes. Ethanol rinse at 5000 rpm for 30 seconds followed to remove unattached molecules. Next, a 1.4 M solution of FA<sub>0.85</sub>CS<sub>0.15</sub>PbI<sub>3</sub> in DMF/DMSO (7:3 v/v) was spin-coated onto the MeO-4PACz layer at 500 rpm for 8 seconds, followed by 3000 rpm for 25 seconds. The ethyl acetate (450 μL) was dropped onto the substrate 10 seconds before spinning ended. The resulting perovskite layer was annealed at 100 °C for 50 minutes. Subsequently, the (n-doped) PC<sub>61</sub>B-TEG solution was spin-coated on the perovskite layer at 5000 rpm for 30 seconds and annealed at 100 °C for 10 minutes. A 30 nm-thick C<sub>60</sub> layer was thermally evaporated under high vacuum ( $< 5 \times 10^{-5}$  torr) at an evaporation rate of 0.5 Å. A 100 nm thick Ag electrode was evaporated through a shadow mask, defining the active area to 0.135 cm<sup>2</sup>. Additionally, LiF (70 nm thick) was evaporated on the glass side to mitigate reflection loss from the glass substrate.

### Supplementary note 1

## Thermal conductivity measurement

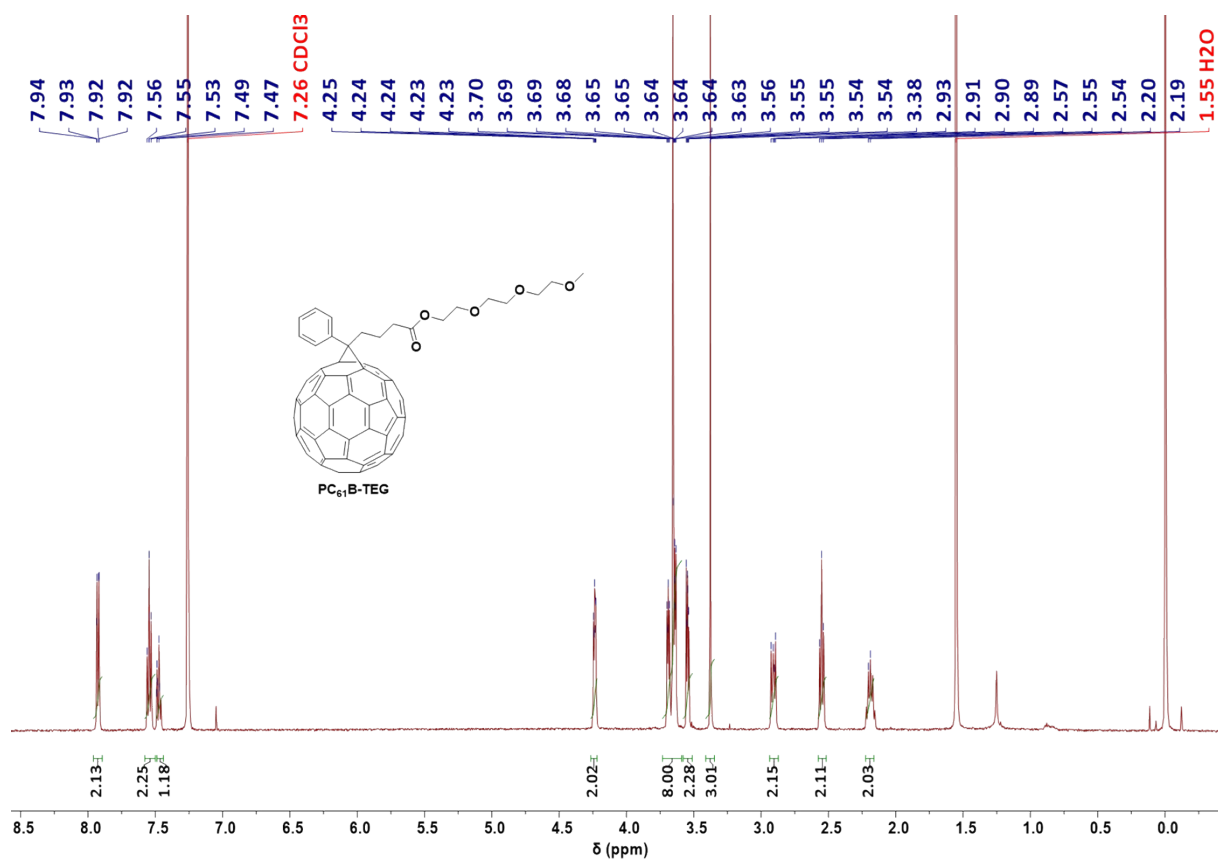
Thermal conductivity ( $\kappa$ ) measurements were conducted using a time-domain thermoreflectance (TDTR) technique. A detailed description of the measurement principle and experimental setup can be found elsewhere.<sup>3-4</sup> A femtosecond pulsed laser, generated by a Ti:Sapphire oscillator with an 80 MHz repetition rate, was split into pump and probe beams using a half-wave plate and a polarized beam splitter (PBS). The pump beam passed through an electro-optic modulator (EOM) with sinusoidal modulation, followed by frequency doubling through a bismuth borate (BIBO) crystal. The probe beam, delayed by a mechanical stage ranging from 0 to 5000 ps, was coaxially excited with the pump beam at the sample surface. Reflectance changes induced by the pump beam were measured using the probe beam. A thin layer of aluminum film (80 nm) deposited on the top layer of the sample served as an opto-thermal transducer. The thermal conductivity ( $\kappa$ ) of the sample was determined by fitting experimental data to thermal modeling.



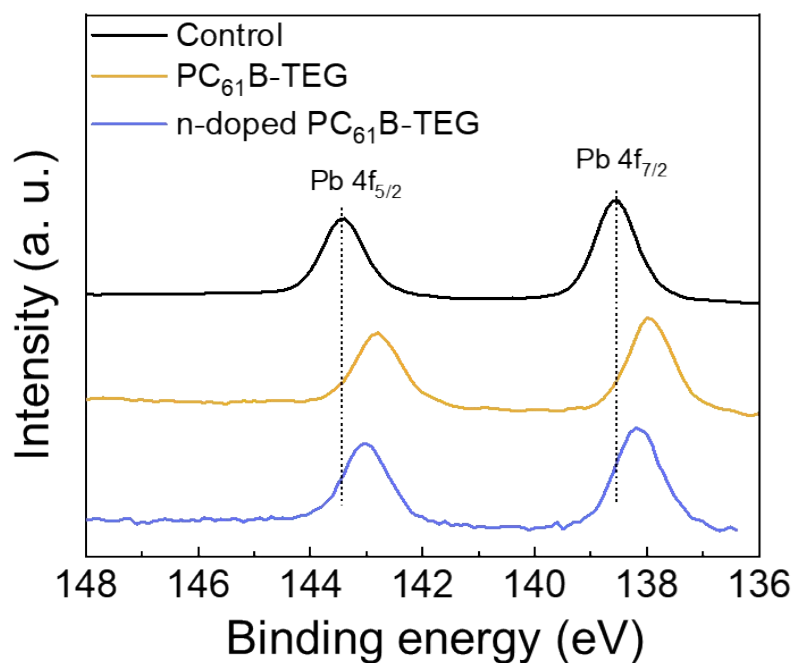
Schematics of TDTR measurement and sample structure.

## Heat capacity measurement

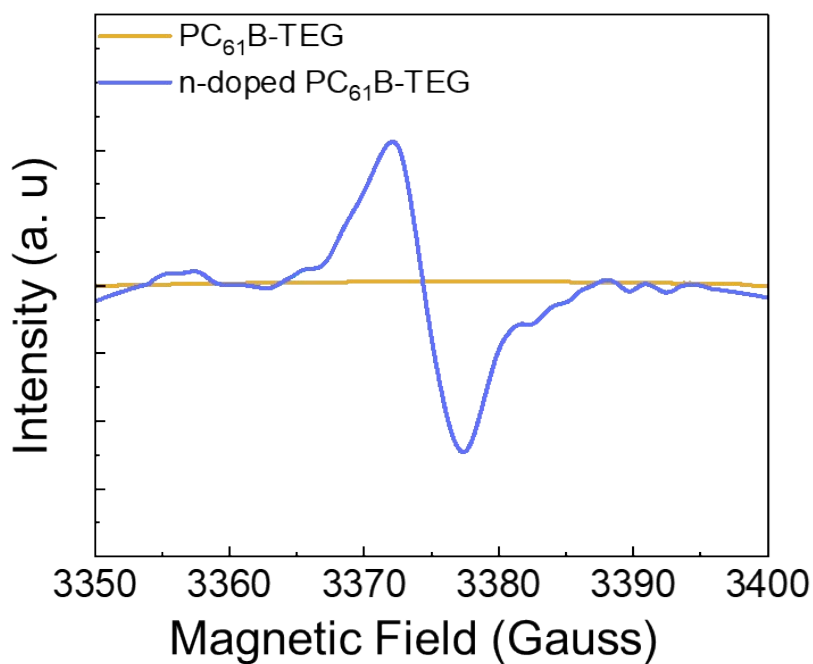
The volumetric heat capacity ( $C_v$ ) of the PC<sub>61</sub>B-TEG samples was estimated by multiplying the specific heat capacity ( $C_p$ ) by the density of PC<sub>61</sub>B-TEG ( $\rho$ ). The  $C_p$  value was obtained from differential scanning calorimetry (DSC) using Q200 (TA Instrument) (see Fig. S5, ESI†), while  $\rho$  was approximated to the density of [6,6]-phenyl C<sub>61</sub> butyric acid methyl ester (PCBM) at 1.5 g/cm<sup>3</sup>. The  $C_p$  was measured using a step scan isothermal method from 20 to 30 °C with a scan rate of 0.1 °C/minute and a 10-minute hold at every interval.



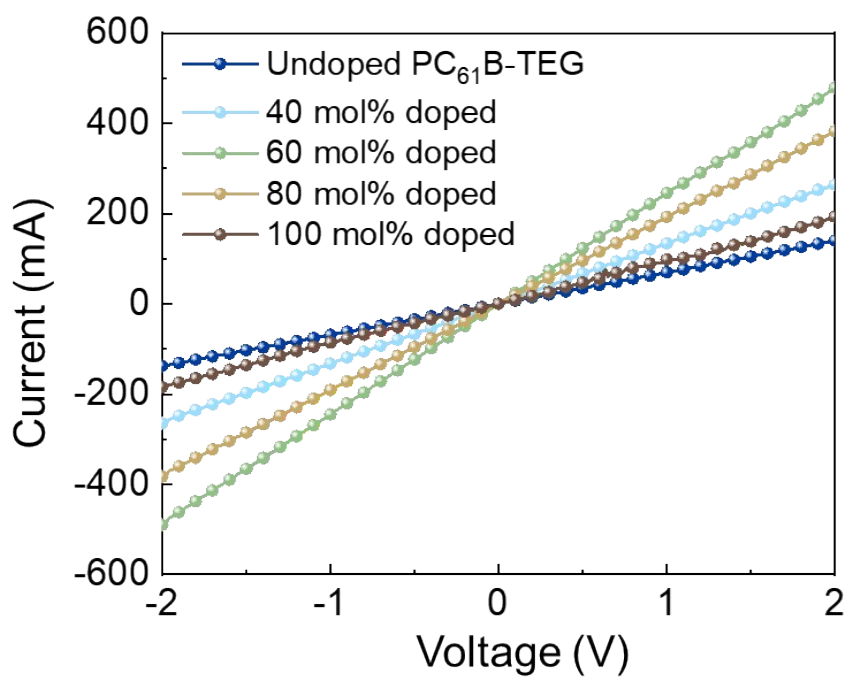
**Fig. S1** <sup>1</sup>H-NMR spectrum of PC<sub>61</sub>B-TEG in CDCl<sub>3</sub>.



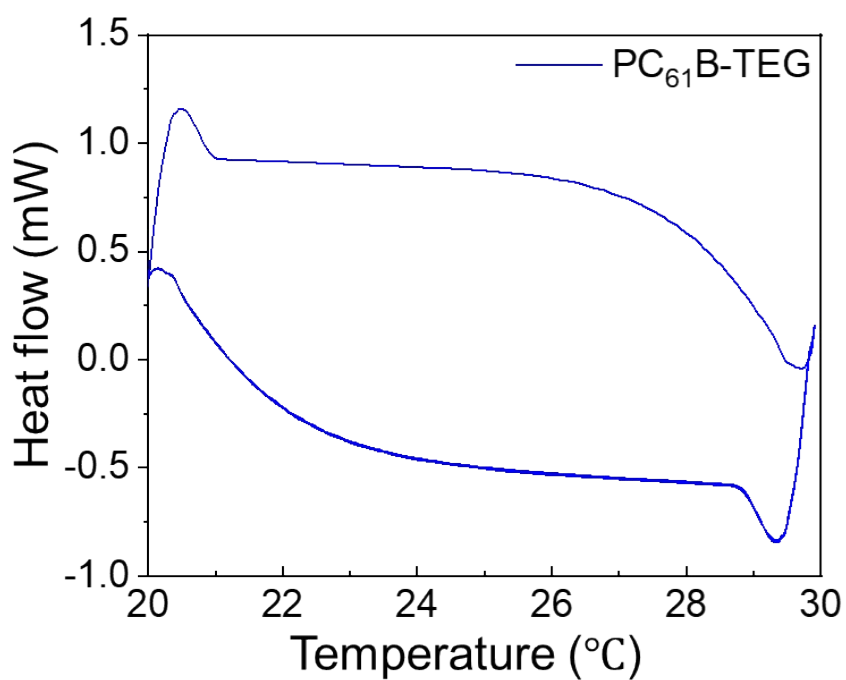
**Fig. S2** Pb 4f XPS spectra of perovskite films with and without PC<sub>61</sub>B-TEG and n-doped PC<sub>61</sub>B-TEG.



**Fig. S3** EPR signal of PC<sub>61</sub>B-TEG doped with N-DMBI as dopant.

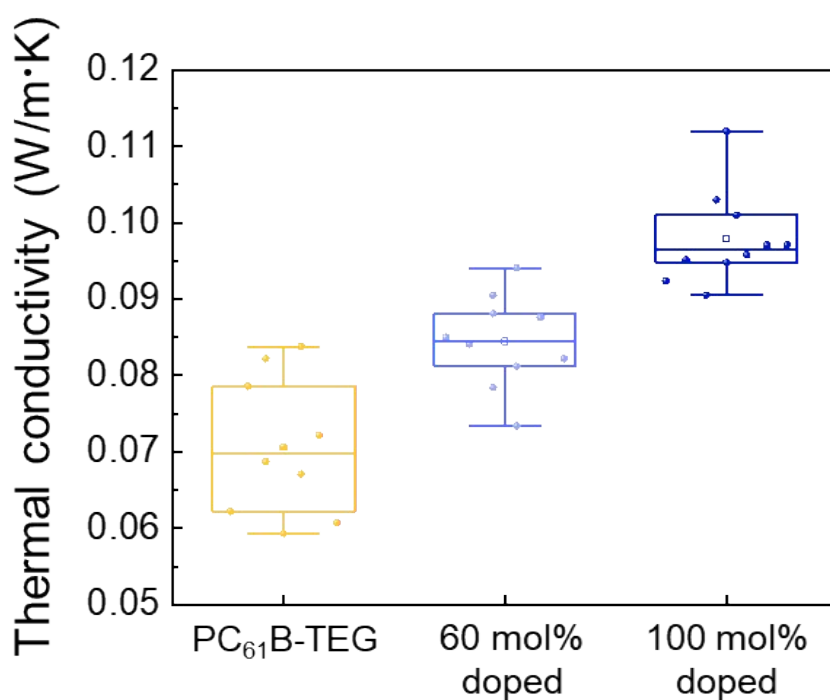


**Fig. S4** Electrical conductivity of PC<sub>61</sub>B-TEG films depending on doping concentration.

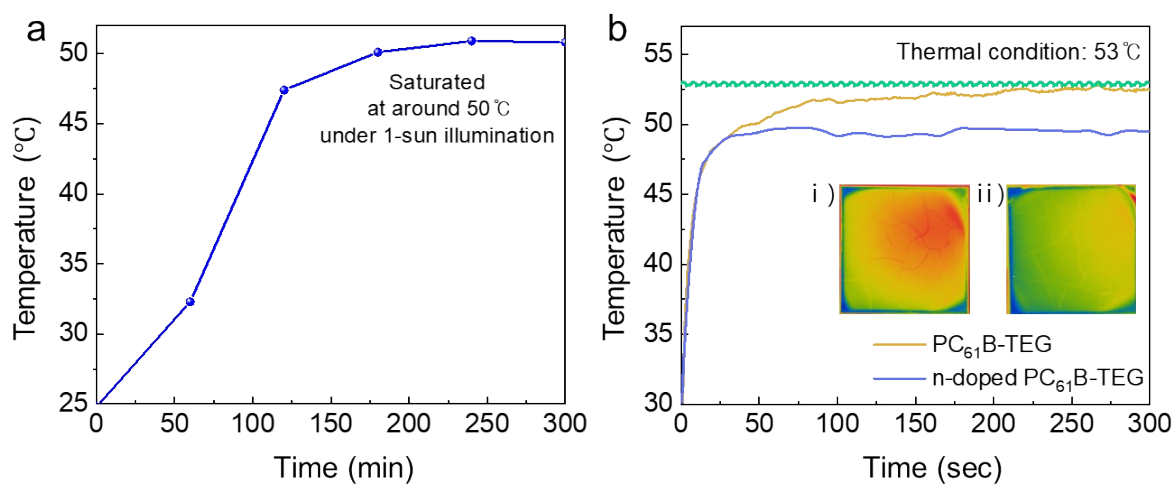


**Fig. S5** DSC thermogram of PC<sub>61</sub>B-TEG.

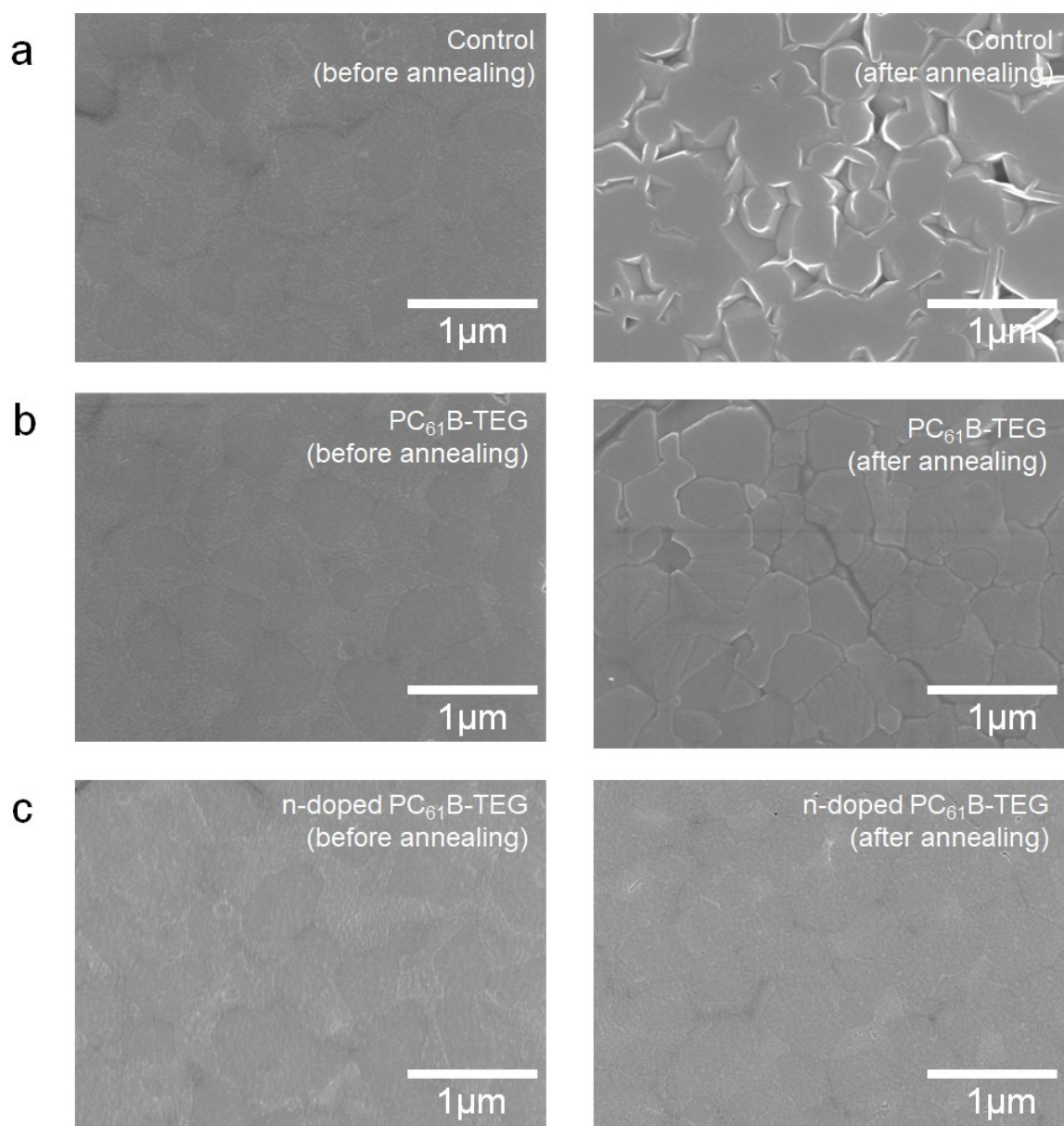




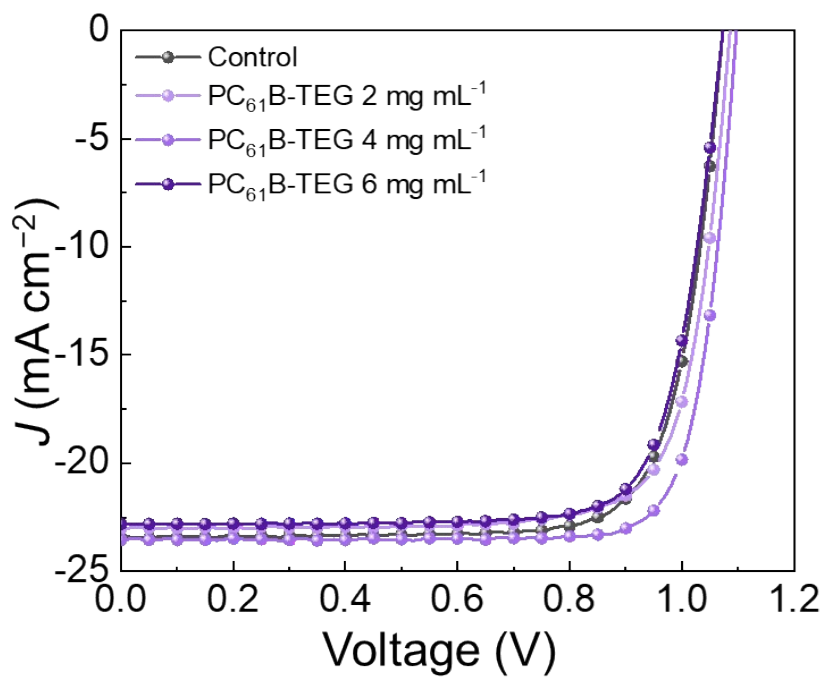
**Fig. S6** Thermal conductivity statistics of undoped PC<sub>61</sub>B-TEG and PC<sub>61</sub>B-TEG doped with N-DMBI (60 and 100 mol%).



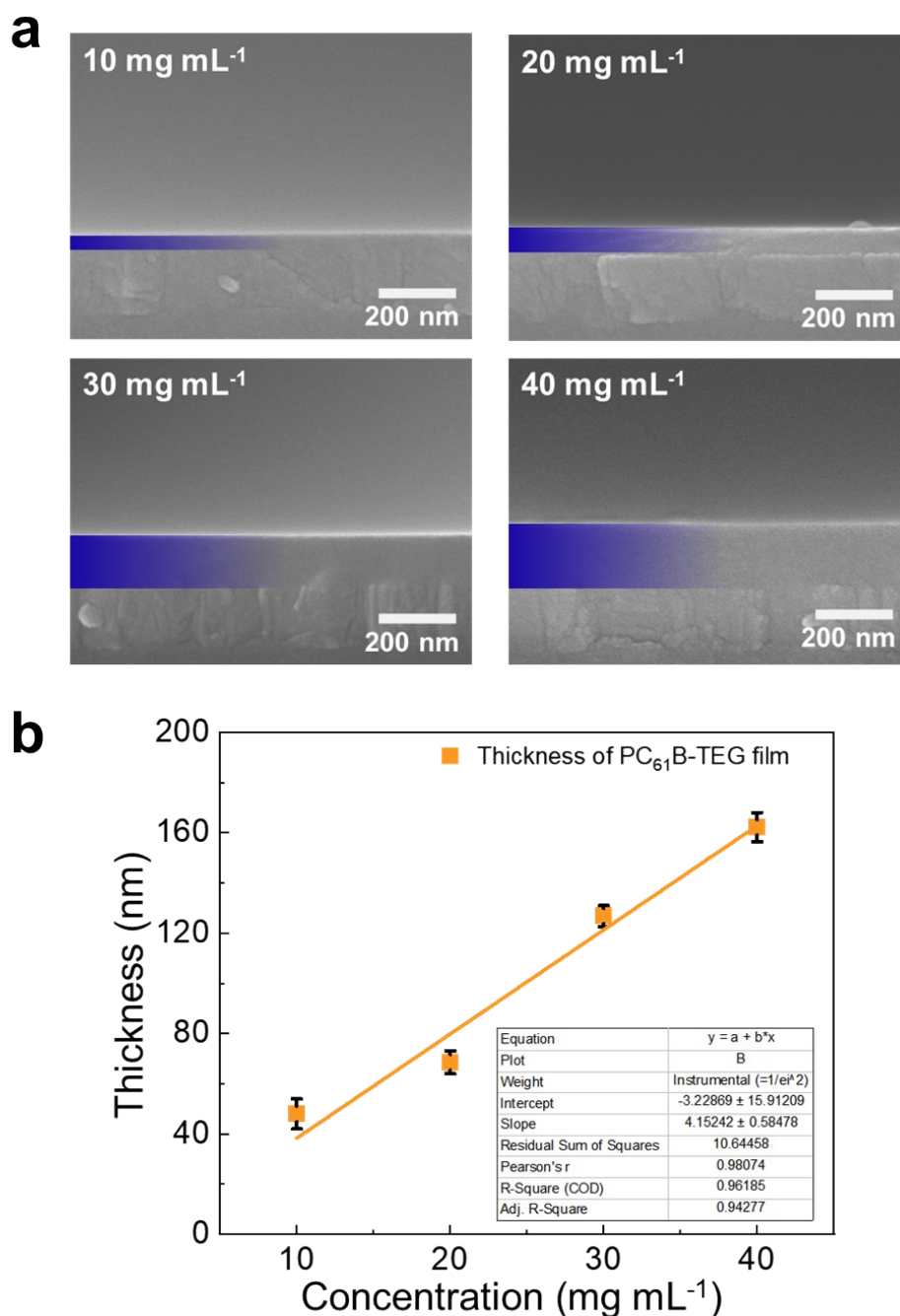
**Fig. S7** (a) Temperature increment under 1-sun illumination condition of AM 1.5 G ( $100 \text{ mW cm}^{-2}$ ) (b) Temperature profiles of perovskite/PC<sub>61</sub>B-TEG film with and without n-doping under  $53 \text{ }^\circ\text{C}$  continuous heat. Insets are IR camera images of perovskite/PC<sub>61</sub>B-TEG films of i) without and ii) with n-doping heated continuously for 5 minutes at  $53 \text{ }^\circ\text{C}$ .



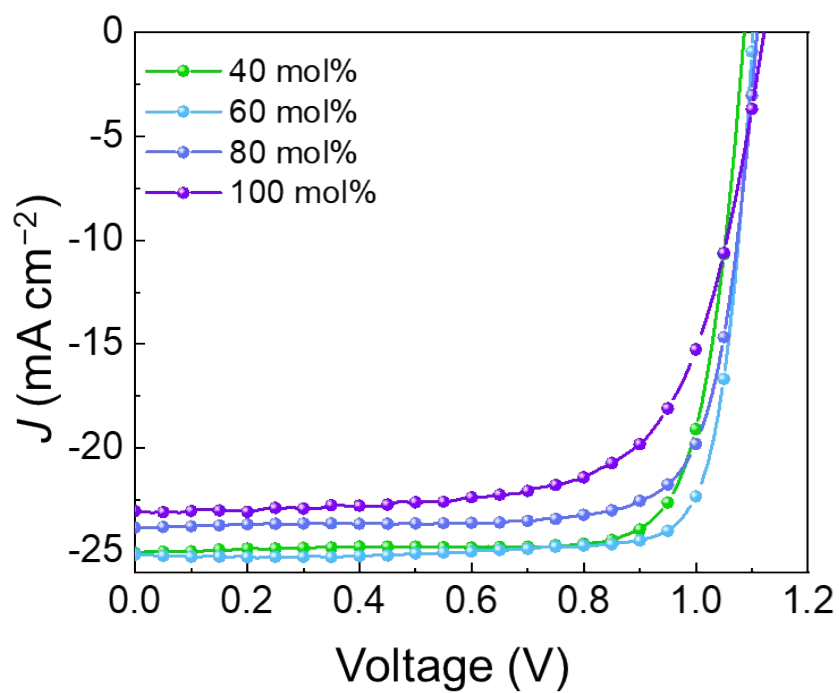
**Fig. S8** SEM images of the bottom side perovskite films (a) without (control) and (b) with PC<sub>61</sub>B-TEG, and (c) n-doped PC<sub>61</sub>B-TEG. The “after annealing” samples were heated at 120 °C for 72 hours in N<sub>2</sub>.



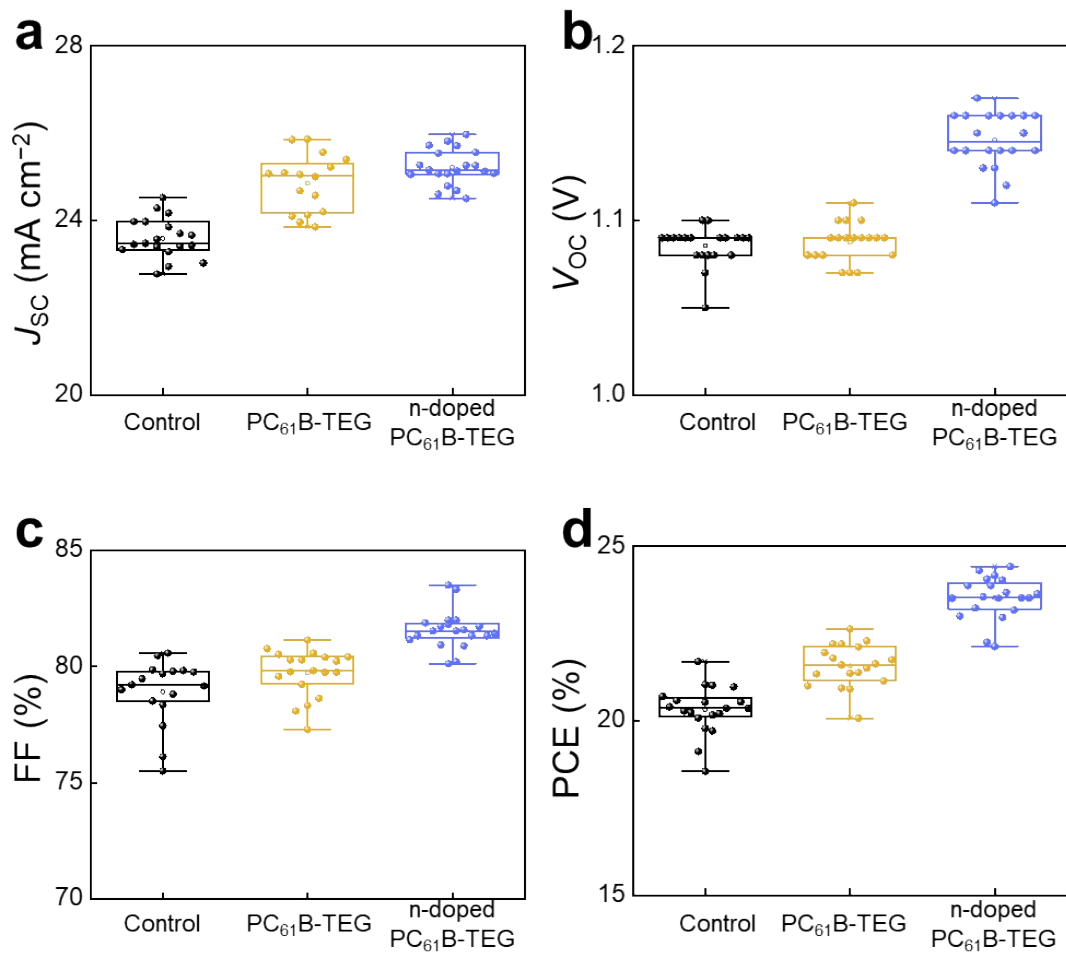
**Fig. S9**  $J$ - $V$  curve of PeSCs with a  $\text{PC}_{61}\text{B-TEG}$  top interlayer with variation of its concentration.



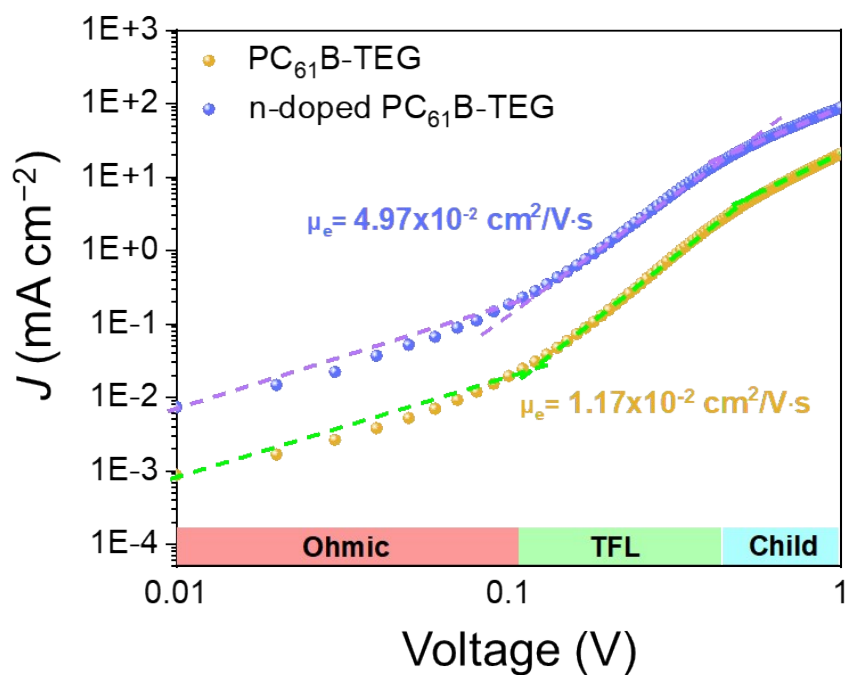
**Fig. S10** Thickness confirmation of PC<sub>61</sub>B-TEG (a) SEM images of cross-sections PC<sub>61</sub>B-TEG depend on various concentration. PC<sub>61</sub>B-TEG films are fabricated by spin coating PC<sub>61</sub>B-TEG solutions (dissolved in chloroform) in 5000 rpm for 30 sec on ITO substrates. (b) Correlation between the concentration of PC<sub>61</sub>B-TEG solution and thickness of PC<sub>61</sub>B-TEG film.



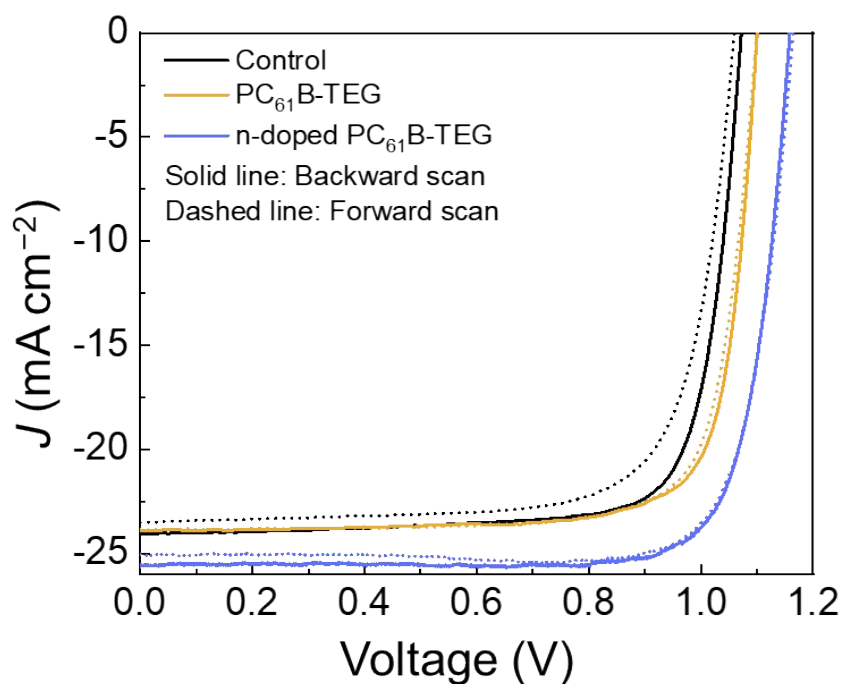
**Fig. S11**  $J$ - $V$  curve of PeSCs with n-doped  $\text{PC}_{61}\text{B}$ -TEG interlayer by varying doping concentration.



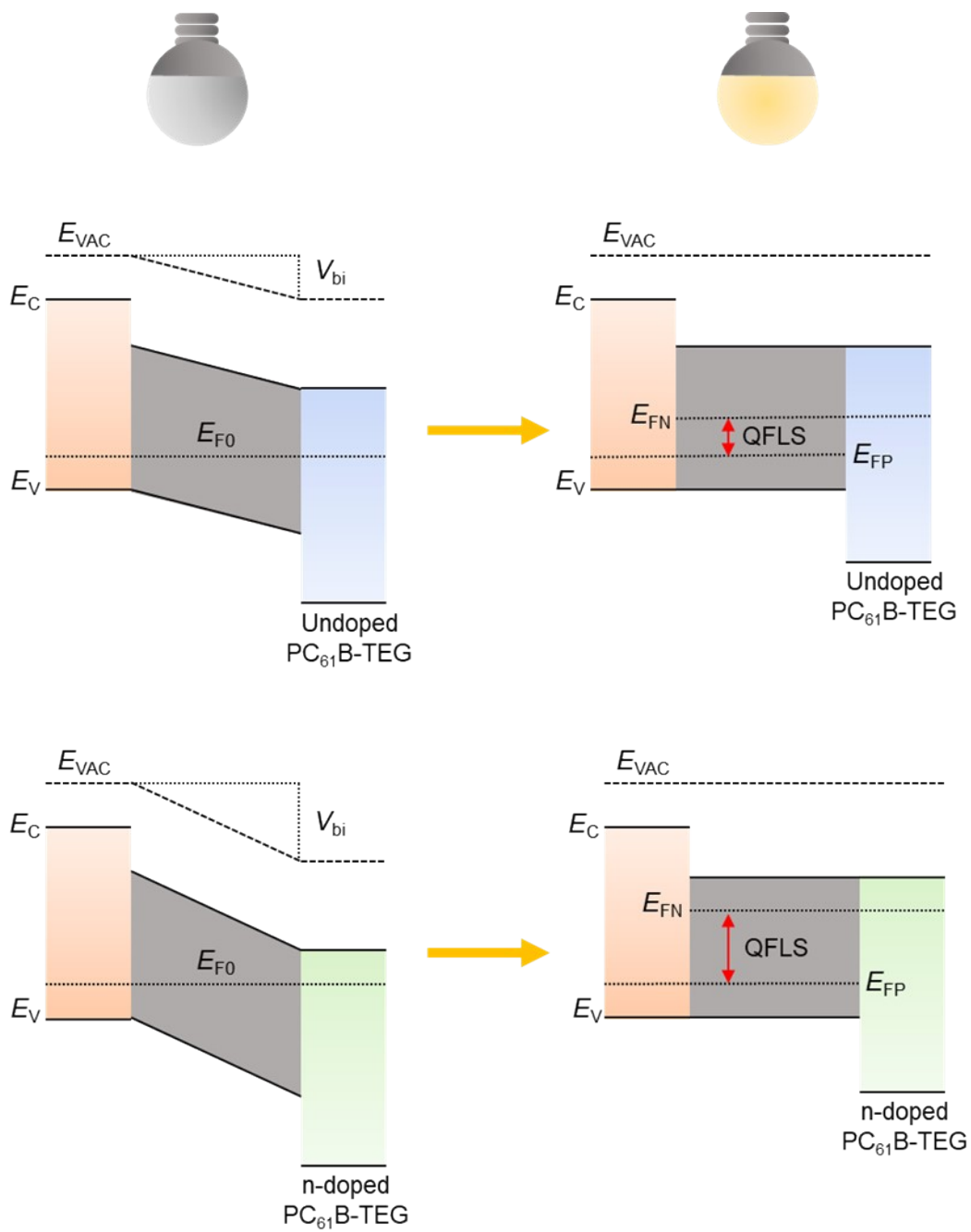
**Fig. S12** Statistics of photovoltaic parameters of PeSCs (a)  $J_{SC}$ , (b)  $V_{OC}$  (c) FF and (d) PCE of control, PC<sub>61</sub>B-TEG and n-doped PC<sub>61</sub>B-TEG .



**Fig. S13** SCLC curves of electron-only devices with an architecture of ITO/SnO<sub>2</sub>/(n-doped) PC<sub>61</sub>B-TEG/LiF/Ag.

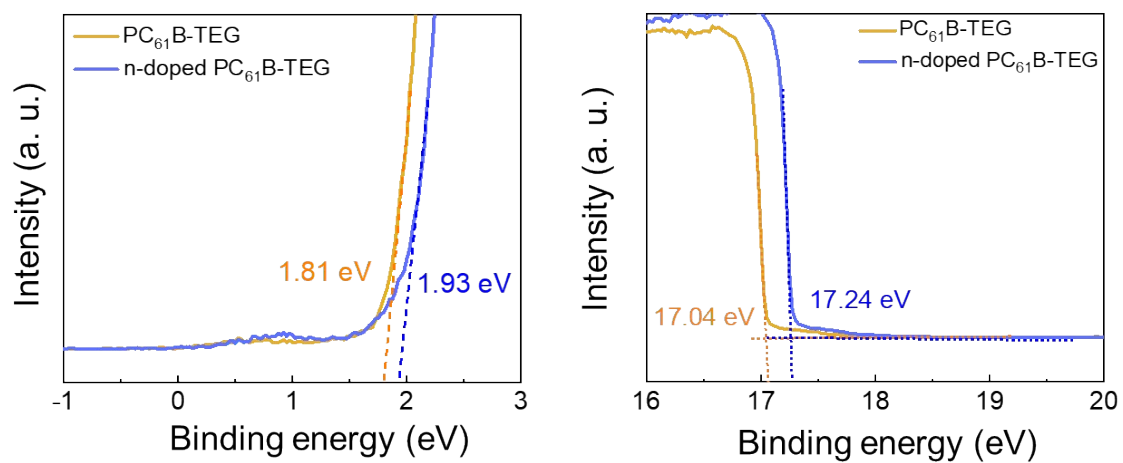


**Fig. S14**  $J$ - $V$  curves of Control, PC<sub>61</sub>B-TEG and n-doped PC<sub>61</sub>B-TEG treated PeSCs under forward and backward scans.



**Fig. S15** Illustrations of QFLS in PeSCs with undoped PC<sub>61</sub>B-TEG and n-doped PC<sub>61</sub>B-TEG interlayers.





**Fig. S16** UPS measurement of PC<sub>61</sub>B-TEG and n-doped PC<sub>61</sub>B-TEG in optimized doping concentration.

**Table S1** Resistance and electrical conductivity of PC<sub>61</sub>B-TEG and n-doped PC<sub>61</sub>B-TEG films (40, 60, 80, 100 mol%).

Doping concentration	Resistance [Ω]	Conductivity [S cm <sup>-1</sup> ]
PC <sub>61</sub> B-TEG	14.27	4.41 × 10 <sup>-4</sup>
40 mol%	7.54	1.19 × 10 <sup>-3</sup>
60 mol%	4.13	2.17 × 10 <sup>-3</sup>
80 mol%	5.24	1.17 × 10 <sup>-3</sup>
100 mol%	10.87	8.24 × 10 <sup>-4</sup>

**Table S2** XRD peak area ratios of PbI<sub>2</sub>/(100) for control, PC<sub>61</sub>B-TEG, and n-doped PC<sub>61</sub>B-TEG treated cells before and after thermal treatment at 120 °C for 72 hours.

	PbI <sub>2</sub> /(100) before treatment	PbI <sub>2</sub> /(100) after treatment
Control	0.186	3.128
PC <sub>61</sub> B-TEG	0.166	1.492
n-doped PC <sub>61</sub> B-TEG	0.101	0.197

**Table S3** Photovoltaic parameters of PeSCs with undoped PC<sub>61</sub>B-TEG interlayer.

Concentration of PC <sub>61</sub> B-TEG	<i>J</i> <sub>sc</sub> [mA cm <sup>-2</sup> ]	<i>V</i> <sub>oc</sub> [V]	FF [%]	PCE [%]
Control	23.43	1.07	76.93	19.47
2 mg mL <sup>-1</sup>	23.04	1.09	77.53	19.47
4 mg mL <sup>-1</sup>	23.67	1.1	81.45	21.11
6 mg mL <sup>-1</sup>	22.81	1.08	77.44	19.08

**Table S4** Photovoltaic parameters of PeSCs with undoped PC<sub>61</sub>B-TEG interlayer.

Doping concentration	<i>J</i> <sub>sc</sub> [mA cm <sup>-2</sup> ]	<i>V</i> <sub>oc</sub> [V]	FF [%]	PCE [%]
40 mol%	25.05	1.09	79.24	21.64
60 mol%	25.13	1.11	81.82	22.83
80 mol%	22.71	1.12	71.58	18.21
100 mol%	23.02	1.13	68.53	17.83

**Table S5** Photovoltaic parameters of control and (n-doped) PC<sub>61</sub>B-TEG treated PeSCs under backward and forward scans.

Device	Scan direction	$V_{OC}$ [V]	$J_{SC}$ [mA cm <sup>-2</sup> ]	FF [%]	PCE [%]	HI <sup>a)</sup> [%]
Control	Backward	1.08	24.05	77.78	20.21	8.21
	Forward	1.05	23.51	75.10	18.55	
PC <sub>61</sub> B-TEG	Backward	1.11	23.88	78.79	20.89	1.15
	Forward	1.09	23.84	79.48	20.65	
n-doped PC <sub>61</sub> B-TEG	Backward	1.16	25.60	80.36	23.85	0.88
	Forward	1.16	25.05	80.99	23.64	

a) Hysteresis index.

## References

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